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Direct Intercalation of MoS₂ and WS₂ Thin Films by Vacuum Filtration

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New Concepts

We demonstrate for the first time a versatile new approach for preparing thin-film intercalation compounds of transition metal dichalcogenides (TMDCs). Because of their transformative potential in a wide variety of catalytic, electronic, sensing, and energy storage applications, intercalation compounds of TMDCs have been explored, often in the form of a slurry. This limits the quality and processability of the materials. These synthetic procedures also lack generality and often need to be modified and re-optimized for different classes of compounds. Here we present an easy route to intercalate molecules into TMDCs in a thin-film morphology. We use vacuum filtration to accelerate the intercalation of guest species into MoS₂ and WS₂ films restacked from exfoliated nanosheets. This work demonstrates the intercalation of electron-proton transfer mediators into the MoS₂ and WS₂ for the first time. Our approach also accommodates a great variety of intercalants from organometallics to alkylamines. This method is easily generalizable to other layered materials in a thin-film morphology, paving the way for their expanded investigation and application in next-generation technologies.

Direct Intercalation of MoS₂ and WS₂ Thin Films by Vacuum Filtration

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Abstract

In the development of next-generation electronics and energy devices, intercalation compounds of transition metal dichalcogenides (TMDCs) are gaining attention for their unique properties that result from synergistic interactions between guest species and host materials. Nowadays, intercalation compounds of MoS₂ and WS₂ are commonly prepared by a two-step process: 1) exfoliation to form single-layer and/or few-layer nanosheets and 2) restacking the nanosheets with the guest species by vigorously mixing the exfoliated suspension with the solution of guest species. While a wide variety of intercalation compounds have been synthesized using this approach, the intercalation process is often time-consuming, and the product slurry limits their quality, impeding characterization and application. Herein, we report a versatile method for preparing intercalated TMDCs in a thin-film morphology. Using this approach, we successfully prepared a range of existing intercalation compounds of MoS₂ and WS₂ (*e.g.*, ferrocene and amine intercalated MoS₂). Additionally, by leveraging the versatility of this intercalation method, we intercalated phenazine and benzoquinone into MoS₂ and WS₂ for the first time.

Introduction

Intercalation compounds of transition metal dichalcogenides (TMDCs) offer a wide variety of physicochemical properties through the combination of guest species and intrinsic traits of the host TMDCs.¹⁻⁴ The building blocks of TMDCs are layers represented as TX_2 where T is the transition metal atom and X is chalcogen atom. These layers are loosely bound to each other via van der Waals interactions. This unique layered structure enables intercalation with a great variety of guest species into the van der Waals gap between these layers.^{5,6} Among all the TMDCs, intercalation compounds of group VI TMDCs (*e.g.*, MoS_2 and WS_2) have attracted attention because of their great potential in applications of energy storage, electronics, and catalysis.⁷⁻⁹ The expansion of the interlayer distance due to intercalation has been applied to reduce the energy barrier for alkali ion batteries.¹⁰ Ye *et al.* have also demonstrated superconductivity of intercalated MoS_2 .¹¹ Moreover, intercalation compounds of MoS_2 and WS_2 have shown enhanced activity for the hydrogen evolution reaction by modifying the electronic structure of the catalysts.^{12,13}

Group VI TMDCs are, however, one of the most challenging host materials among the TMDCs for intercalation. Intercalation generally involves a charge transfer process from the guest species (electron donors) to the layered hosts (electron acceptors). Because of their low electron affinity, MoS_2 and WS_2 are much weaker electron acceptors.¹⁴ Only strong electron donors (*e.g.*, n-butyllithium) can be intercalated into MoS_2 and WS_2 directly; in contrast, much weaker electron donors can be intercalated into group IV and V TMDCs. For example, direct intercalation of ammonia into TiS_2 ¹⁵ and intercalation of pyridine into TaS_2 are facile.¹⁶

To expand the variety of guest species in group VI TMDCs, several strategies have been explored. Electrochemical intercalation has enabled a great variety of intercalation compounds of MoS_2 with positively charged intercalants from small alkali cations,¹⁷⁻¹⁹ to alkylammonium cations.^{20,21} Instead of accepting electrons from electron donors, this approach injects electrons into the conduction band of MoS_2 by applying a reducing potential. The Coulomb interaction between the negatively charged MoS_2 layers and the cations further drives the intercalation process.²² The disadvantage of this approach is the limitation of guest species to cations. Alternatively, restacking the exfoliated MoS_2 and WS_2 layers in a solution with guest species is another method to prepare intercalation compounds of MoS_2 and WS_2 . Guest species such as cations,^{23,24} polymers,^{25,26} and clusters²⁷ have been successfully intercalated into MoS_2 and WS_2 using this method. This strategy has also been applied to intercalating organometallic compounds (*e.g.*, metallocenes) and organic molecules that are not electron donors (*e.g.*, naphthalene) into MoS_2 .^{28,29} The intercalation occurs after vigorously mixing an aqueous suspension of single layer MoS_2 and (usually) an immiscible organic solvent that contains the guest species.

While there are many different categories of guest species that have been intercalated into MoS_2 and WS_2 , the experimental procedure needs to be designed separately in each case and some of syntheses require several days.^{1,30} Moreover, the products are often generated in the form of a slurry, which may limit the processability and quality of the intercalated materials. For example, sonication is commonly required to form a suspension for deposition of a high-quality film for electrochemical characterization. However, these intercalation compounds may de-

intercalate during sonication^{31,32} which complicates the characterization of the intercalation compounds.

Herein, we developed a versatile method for intercalating different categories of guest species into restacked MoS₂ and WS₂ thin films. Pioneering work by Talyzin *et al.* has shown that solvents can intercalate into restacked graphene oxide membranes.³³ Similarly, Ries *et al.* have demonstrated that the functionalization of the MoS₂ can be achieved in the form of restacked MoS₂ via vacuum filtration.³⁴ These studies suggest that small molecules can easily diffuse into the space in between the sheets of layered materials. Inspired by their work, we used vacuum filtration to accelerate the diffusion of guest species and encapsulate them in the van der Waals' gap. We applied this approach to three different categories of guest species including organometallic compounds, n-alkylamines, and electron-proton transfer mediators in both MoS₂ and WS₂. Our approach enables the facile synthesis of a great variety of intercalation compounds of MoS₂ and WS₂ in a thin-film morphology, which opens new doors to developing electrocatalysts and energy storage materials.

Results and Discussion

Figure 1a shows an optical image of a restacked MoS₂ film obtained by vacuum filtration. The thickness of the film can be controlled by the volume of exfoliated MoS₂ suspension used in the filtration.³⁵ From our scanning electron microscopy characterization, the thickness of a representative MoS₂ film is ~ 1 μm (**Figure 1b**). As shown by previous studies,³⁶ the phase of chemically exfoliated MoS₂ is predominantly 1T phase (~ 70%) agreeing with our Raman and UV-Vis spectroscopic analysis (**Figure S1-2**). **Figure 1c** shows that this thin film can be transferred to other surfaces such as conductive substrates (*e.g.*, gold) for further application.³⁵ The WS₂ films prepared via vacuum filtration (**Figure S3-4**) demonstrate similar features, including having controllable thickness and being easily transferrable.

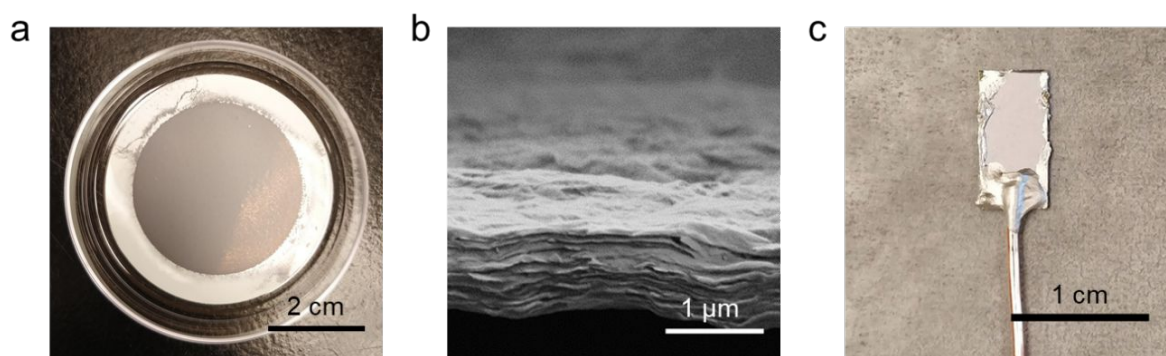


Figure 1. (a) Optical image of a representative restacked MoS₂ film on a nitrocellulose membrane. (b) SEM cross sectional image of a representative restacked MoS₂ film. (c) Optical image of an electrode prepared by transferring a restacked MoS₂ film onto a gold substrate. The edges of the electrode were sealed using silver paint.

The first class of guest species we explored were metallocenes, which have been intercalated into TMDCs previously owing to their interesting spin and electronic properties for superconductivity and catalysis.^{1,12} We intercalated ferrocene (Cp_2Fe), 1,1'-dimethylferrocene ($(\text{MeCp})_2\text{Fe}$), and decamethylferrocene ($(\text{Me}_5\text{Cp})_2\text{Fe}$) into MoS_2 and WS_2 . X-ray diffraction (XRD) clearly demonstrated the expected lattice expansion arising from intercalation (**Figure 2**). The XRD results show that the distance between layers in our restacked MoS_2 and WS_2 are ~ 6.2 Å which agree with the bulk materials.^{37,38} In the XRD of intercalation compounds, the peaks corresponding to the restacked MoS_2 and WS_2 disappear indicating no residual restacked MoS_2 and WS_2 . We found the distance between host sheets in the Cp_2Fe intercalated MoS_2 and WS_2 are both 11.8 Å consistent with the previous literature.^{23,28} The expansion (~ 5.6 Å) is close to the van der Waals diameter of a cyclopentadienyl (Cp) ring suggesting the ring is perpendicular to the host layers.³⁹ Similar expansion (~ 5.6 Å) was observed in the $(\text{MeCp})_2\text{Fe}$ intercalated MoS_2 and WS_2 . We hypothesize that the Cp ring is still perpendicular to the host sheets but the methyl group in MeCp is pointing away from the host sheets. In contrast, the distance between the host sheets is ~ 13.4 Å in $(\text{Me}_5\text{Cp})_2\text{Fe}$ intercalated MoS_2 and WS_2 . The expansion (~ 7.2 Å) is close to the size of Me_5Cp , consistent with the ring laying perpendicular to the host sheets. Among the restacked and intercalated films, we only observed diffraction peaks from the $\{001\}$ plane, indicating a preferred orientation along the z-axis in the thin film samples. The distances between the host sheets in the intercalation compounds are summarized in **Table S1**.

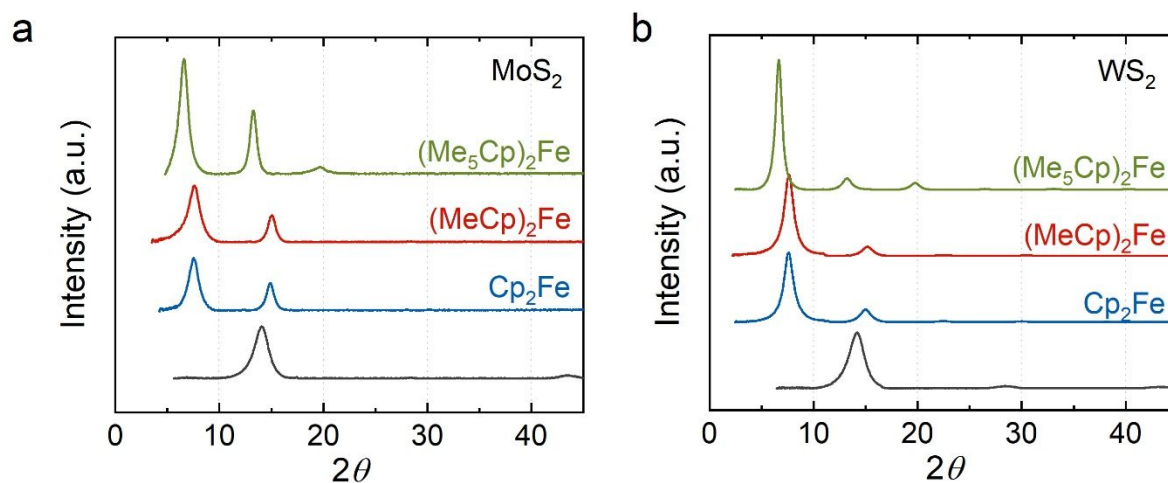


Figure 2. XRD of metallocene intercalated (a) MoS_2 and (b) WS_2 . Green: decamethylferrocene-intercalated; red: 1,1'-dimethylferrocene-intercalated; blue: ferrocene-intercalated; dark gray: restacked.

We quantified the compositions of the metallocene intercalated MoS_2 and WS_2 using inductively coupled plasma optical emission spectroscopy (ICP-OES, **Table 1**). We found that S/Mo ratios are ~ 2 consistent with the stoichiometry of the bulk MoS_2 . The Fe/Mo ratios are 0.118, 0.093, 0.135 in Cp_2Fe , $(\text{MeCp})_2\text{Fe}$, and $(\text{Me}_5\text{Cp})_2\text{Fe}$ intercalated MoS_2 , respectively. The Fe ratio in our compounds is higher than the ferrocene intercalated MoS_2 restacked at the interface of two immiscible solutions (Fe/Mo ~ 0.05).²⁸ However, our ICP-OES results show that

the S/W ratios in the WS₂ intercalation compounds are only ~1.8. To understand this discrepancy, we examined the S/W ratio in the bulk WS₂ and found it is also ~1.8. We hypothesized that the ratio of S/W is lower than the theoretical stoichiometry because of the loss of S during the intense digestion of WS₂ which involves HF and HNO₃. A previous study⁴⁰ suggested the formation of volatile S compounds during sample digestion, resulting in an underestimation of S concentration deduced by ICP-OES analysis. We assumed no formation of volatile Fe and W compounds during the digestion and found that Fe/W ratios are 0.058, 0.072, and 0.092 in three different intercalated WS₂ samples.

Our result shows that the ratio of (Me₅Cp)₂Fe in intercalation compounds is the highest of the metallocene intercalants; however, no clear trend was observed in the ratio of Cp₂Fe and (MeCp)₂Fe. It has been suggested that a more reducing guest species tends to form a more stable intercalation compound.⁴¹ Since the (Me₅Cp)₂Fe is the most reducing guest species ((Me₅Cp)₂Fe > (MeCp)₂Fe > Cp₂Fe),⁴² we expect that (Me₅Cp)₂Fe would form the most stable intercalation compound and therefore be present in the highest ratio. Besides their reducing power, the size of the molecule also affects the ratio of the guest species in the intercalation compounds by determining the maximum packing density. Due to the orientation of the guest species in the intercalation compounds, the maximum packing density of Cp₂Fe is higher than (MeCp)₂Fe. Taken together, the ratio of Cp₂Fe and (MeCp)₂Fe may be a delicate balance influenced by reducing power and the size of intercalant.

Table 1. Composition of the metallocene intercalated MoS₂ and WS₂ from ICP-OES analysis.

Sample	Stoichiometry		
	Mo/W	S	Fe
Cp ₂ Fe-MoS ₂	1	1.99	0.118
(MeCp) ₂ Fe-MoS ₂	1	2.02	0.093
(Me ₅ Cp) ₂ Fe -MoS ₂	1	2.00	0.135
Cp ₂ Fe-WS ₂	1	1.83	0.058
(MeCp) ₂ Fe-WS ₂	1	1.82	0.072
(Me ₅ Cp) ₂ Fe-WS ₂	1	1.79	0.092

In addition, we demonstrated that our approach is applicable to intercalation of n-alkylamines into MoS₂ and WS₂. Alkylamines, which interact with the host materials through their N lone pair, have been successfully intercalated into many layered oxides^{43–45} and TMDCs.^{2,31,32} Yet ammonium cations have been commonly observed as the end product in intercalation compounds of MoS₂ and WS₂ arising from cation exchange reactions in the syntheses.^{31,46} One striking property of these intercalation compounds is that the lattice expansion can be tuned by the chain length of alkylamine. We chose three different chain lengths of alkylamine – octylamine (OA), dodecylamine (DDA), and hexadecylamine (HDA) – to reveal the chain length dependency in our intercalation compounds.

Figure 3 shows the XRD data for the alkylamine intercalated MoS₂ and WS₂. We found the distance between the TMDC sheets increases with the chain length of alkylamine, where OA-MoS₂ is ~ 10.1 Å, DDA-MoS₂ is 14.1 to 14.5 Å, and HDA-MoS₂ is ~ 32.4 Å. We observed a

similar trend in WS_2 intercalation compounds, where OA- WS_2 is $\sim 10.1 \text{ \AA}$, DDA- WS_2 is $\sim 14.3 \text{ \AA}$, and HDA- MoS_2 is $\sim 32.4 \text{ \AA}$. Our results concur with reported n-alkylamine intercalated MoS_2 and WS_2 synthesized through a direct reaction of lithium intercalated TMDCs with an aqueous solution of alkylamine/ammonia.³⁶ However, unlike these compounds, which show a diffraction peak at $2\theta \sim 32^\circ$, our compounds only showed diffraction peaks from the $\{001\}$ plane indicating, again, a preferred orientation along the z-axis.

The non-linear increase of the distance between basal planes is attributed to the orientation of the alkylamine. We hypothesize that a short chain alkylamine (*e.g.*, OA) prefers lying down in the van der Waals gap of the TMDCs. As we showed, the expansion in the OA- MoS_2 and OA- WS_2 are $\sim 3.9 \text{ \AA}$. This value is much shorter than the chain length of OA but close to the van der Waals diameter of the alkyl chain ($\sim 4 \text{ \AA}$). This observation suggests the alkyl chain lies parallel to the host sheets. A similar phenomenon has been reported in alkylammonium intercalated MoS_2 ⁴⁶ and alkylamine intercalated TaS_2 ² where the lattice expansion in short chain amine ($n < 5$) intercalation compounds is $\sim 4 \text{ \AA}$. Interestingly, we found the expansion in DDA- MoS_2 and DDA- WS_2 are $\sim 8.1 \text{ \AA}$ which is close to twice of the size of alkyl chain. We proposed that two layers of DDA sandwiched between the host sheets. However, previous studies have suggested that the alkylamine may form a tilted bilayer structure at an angle from 56° to 68° .^{46,47} If we assume a tilted monolayer DDA in between the host sheets, the tilted angle would be 25.8° much smaller than in the previously reported structures.

In contrast, the distance between host sheets expands to $> 32 \text{ \AA}$ in the HDA intercalated compounds. This expansion is close to the length of the alkyl chain implying a monolayer of HDA perpendicular to the host sheets. We attributed this structural difference to the fact that the longer alkyl chain would have stronger van der Waals interaction among the alkyl chains. This interaction may assist the assembly of the amine and stabilize the perpendicular orientation. Considering the guest species need to diffuse into the film, we note that our materials could be one of several possible kinetically stable phases. Mixtures of intercalation compounds have been found in the alkylamine intercalation TaS_2 .²

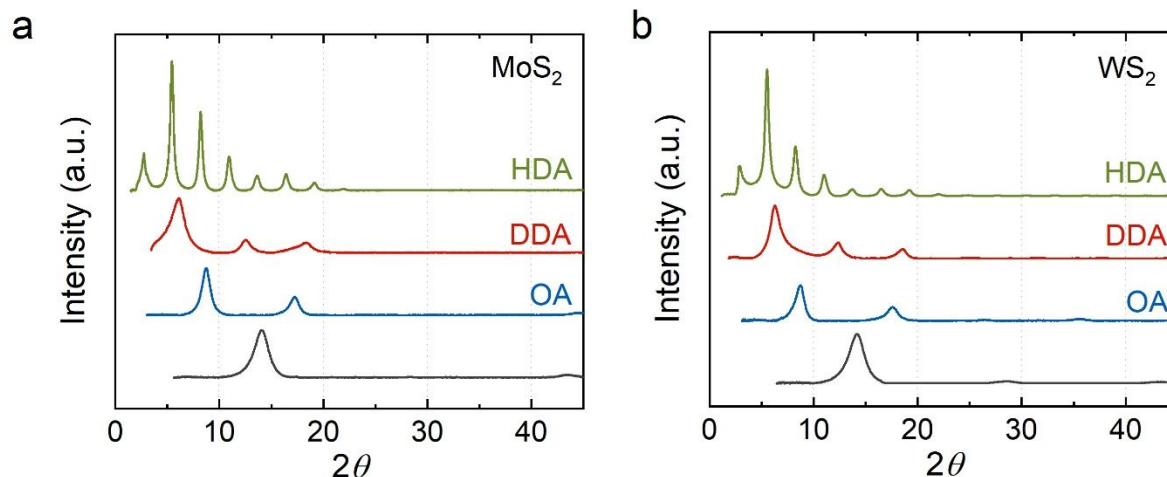


Figure 3. XRD of the n-alkylamine intercalated (a) MoS₂ and (b) WS₂. Green: hexadecylamine-intercalated; red: dodecylamine-intercalated; blue: octylamine-intercalated; dark gray: restacked.

CHN combustion elemental analysis quantified the stoichiometry of OA, DDA, and HDA in both MoS₂ and WS₂ intercalation compounds (**Table 2**). We observed that the stoichiometry of HDA is higher than OA and DDA in both MoS₂ and WS₂ likely because of the orientation of the alkylamines. Compared with the parallel orientation, the perpendicular orientation occupies less projected area on the sheets leading to a higher packing density. We note that mass percentage of carbon from CHN analysis is higher (~ 2 to 3%) than the calculated values from the proposed formula in MoS₂ intercalation compounds, which we attributed to residual carbon compounds adsorbed on the MoS₂. The physical adsorption of solvent has been commonly found on the high-surface-area materials.^{48,49} We examined the composition of restacked MoS₂ and WS₂ without alkylamine and found that the carbon mass percentage is 2.3 % in MoS₂ and only ~ 0.25 % in WS₂.

Table 2. Composition of n-alkylamine intercalated MoS₂ and WS₂ from CHN combustion elemental analysis. Calculated mass percentages are shown in brackets.

Sample	Mass percentage			Approximate formula
	C	H	N	
OA-MoS ₂	9.918 (7.356)	1.719 (1.466)	1.074 (1.072)	OA _{0.136} MoS ₂
DDA-MoS ₂	14.414 (11.178)	2.086 (2.111)	1.093 (1.086)	DDA _{0.145} MoS ₂
HDA-MoS ₂	29.020 (25.855)	4.781 (4.746)	1.869 (1.884)	HDA _{0.319} MoS ₂
OA-WS ₂	7.463 (7.113)	1.404 (1.418)	0.989 (1.037)	OA _{0.203} WS ₂
DDA-WS ₂	9.705 (9.848)	1.651 (1.859)	0.975 (0.957)	DDA _{0.194} WS ₂
HDA-WS ₂	17.155 (17.194)	2.849 (3.156)	1.254 (1.253)	HDA _{0.283} WS ₂

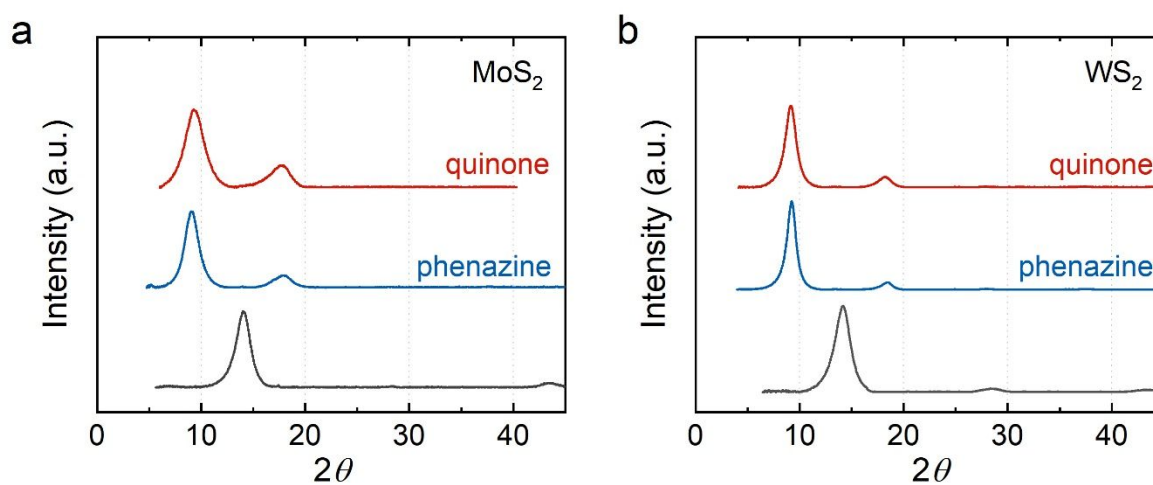


Figure 4. XRD of electro-proton transfer mediator intercalated (a) MoS₂ and (b) WS₂. Red: *p*-benzoquinone-intercalated; blue: phenazine-intercalated; dark gray: restacked.

Finally, our approach enables synthesis of intercalation compounds beyond those that have been synthesized previously. We demonstrated that electron-proton transfer mediators (*e.g.*, phenazine and *p*-benzoquinone) can be intercalated into MoS₂ and WS₂. **Figure 4** shows the XRD of *p*-benzoquinone and phenazine intercalated MoS₂ and WS₂. The expansion from the intercalation is ~ 3.4 Å close to the van der Waals diameter of the carbon atom (3.4 Å). This observation suggests that the carbon ring of the molecules lie parallel to host sheets. We used the size of *p*-benzoquinone (8.3 x 6.6 Å²) and phenazine (11.3 x 7.2 Å²) to estimate their monolayer maximum packing density. In intercalation compounds of MoS₂, the maximum ratio of *p*-benzoquinone is ~ 0.213 whereas the maximum ratio of phenazine is ~ 0.121 . They both show slightly higher packing density in the intercalation compounds of WS₂ (~ 0.223 for *p*-benzoquinone and ~ 0.127 for phenazine) due to the larger lattice constant of WS₂.

We quantified the percentage of phenazine in the intercalation compounds using CHN combustion elemental analysis (**Table 3**). We found that the ratio of phenazine in the intercalation compounds is around 7 to 8%. Interestingly, the mass percentage of carbon is a few percent higher than the calculated value from the proposed formula, similar to what we observed in the alkylamine intercalated MoS₂. We hypothesized that toluene molecules may adsorb and/or intercalate into the MoS₂ and WS₂. To confirm whether toluene can intercalate into MoS₂ and WS₂, we removed the phenazine and only added toluene in the process of vacuum filtration. The XRD of toluene treated MoS₂ and WS₂ (**Figure S5**) shows no shift in the diffraction peak position indicating no intercalation of toluene. While co-intercalation of toluene and phenazine could occur, we expect the lattice expansion from the co-intercalation should be larger. After including toluene (presumed to be adsorbed to the material surface) in the proposed formula, the ratio of phenazine remains ~ 7 to 8% (**Table S2**).

Due to the residual hydrocarbons, we cannot quantify the ratio of *p*-benzoquinone in the intercalation compounds. We estimate its ratio by assuming a constant ratio of residual toluene (*i.e.*, 0.05) in all intercalation compounds. Our estimation shows the ratio of the *p*-benzoquinone is roughly 10 % (**Table S3**). While the structure of the intercalation compounds requires further characterization, our XRD and elemental analysis results confirm the intercalation of phenazine and *p*-benzoquinone in the MoS₂ and WS₂.

Overall, our approach is applicable to guest species whether they are electron-donating (*i.e.*, reducing agents or Lewis bases). Similarly, Morrison et al. reported the intercalation of guest species that are not electron-donating using a biphasic method.²⁸ They observed the formation of intercalation compounds at the interface of two immiscible solvents and they attributed the driving force for this process to the hydrophobic nature of the basal plane of MoS₂. Unlike their approach, the intercalation in our method occurs on a wet restacked TMDC film. Ries et al. have shown that water molecules remain in between MoS₂ layers in the restacked film while it is still wet.³⁴ These water molecules can potentially weaken the van der Waals interactions between host layers. Additionally, the expanded interlayer spacing may reduce the energy barrier for the diffusion of the guest species.¹⁰ Here, we propose the mechanism of intercalation as follows: the guest species (and solvent molecules) replace water molecules in the van der Waals gap of the host materials due to the hydrophobic surface of TMDCs and the pressure gradient generated by the vacuum filtration. After the drying process, the volatile solvent molecules escape from the intercalation compounds due to weaker van der Waals interactions with the TMDCs layers whereas the guest species remain in between the TMDCs layers.

Table 3. Compositions of the phenazine intercalated MoS₂ and WS₂ from CHN elemental analysis. Calculated mass percentages are shown in the brackets.

Sample	Mass percentage			Approximate formula
	C	H	N	
Phenazine-MoS ₂	9.154 (6.834)	0.76 (0.382)	1.326 (1.328)	(C ₁₂ H ₈ N ₂) _{0.083} MoS ₂
Phenazine -WS ₂	5.467 (3.819)	0.654 (0.214)	0.745 (0.742)	(C ₁₂ H ₈ N ₂) _{0.069} WS ₂

Conclusion

We presented a versatile approach for directly intercalating guest species into MoS₂ and WS₂ restacked thin films. A key feature of our intercalated materials is the easily transferrable thin-film morphology. We synthesized known ferrocene and n-alkylamine intercalated MoS₂ and WS₂ compounds via vacuum filtration. Moreover, we intercalated two electron–proton transfer mediators (*i.e.*, phenazine and benzoquinone) into MoS₂ and WS₂ for the first time. This method should be broadly applicable to intercalating other exfoliated layered materials (*e.g.*, graphene oxide and MXenes) with a broad range of guest species, which will accelerate the study of intercalation compounds in catalysis, sensing, energy storage, and beyond.

Experimental Methods

Materials. Molybdenum(IV) sulfide powder (< 2 μm , 99 %), tungsten(IV) sulfide powder (2 μm , 99 %), n-butyllithium solution (1.6 M in hexane), ferrocene (98 %), 1,1'-dimethylferrocene (95 %), bis(pentamethylcyclopentadienyl)iron(II) (97 %), phenazine (98 %) were purchased from Sigma-Aldrich and used as received without further purification. *p*-Benzoquinone (99.5 %) was purchased from Sigma-Aldrich and purified via sublimation. Octylamine (99 %), dodecylamine (98 %), and hexadecylamine (98 %) were purchased from Sigma-Aldrich and heated at 100 °C for 10 min under nitrogen prior to use. Pentane was purchased anhydrous and stored over 3 Å molecular sieves prior to use. Hexane (98.5 %, Sigma Aldrich), toluene (99.8 %, Fisher Chemical), methanol (99.9 %, Fisher Chemical) were used as received without further purification.

Exfoliation of MoS₂ and WS₂. The exfoliation was performed by using the lithium intercalation method that has been reported previously.³⁵ Briefly, 320 mg of MoS₂ was charged into an oven-dried 50 mL Schlenk flask. After degassing and cycling with nitrogen three times, 5 mL 1.6 M n-butyllithium solution in hexane was added. The flask was at room temperature and stirring at 300 rpm for 48 hr under nitrogen. After 48 hr, the flask was transferred into a nitrogen glovebox. Pentane was added to wash the materials at least 3 times. The Li_xMoS₂ was stored under nitrogen. 497 mg of WS₂ was added into an oven-dried three-neck round bottom flask. 5 mL 1.6 M n-butyllithium solution in hexane was added. The solution was refluxed at 70 °C with magnetic stirring at 300 rpm for 48 hr under nitrogen. After 48 hr, the flask was transferred into a nitrogen glovebox. Pentane was added to wash the materials at least 3 times. The Li_xWS₂ was stored under nitrogen.

~ 67.5 mg of Li_xMoS₂ (~ 100 mg of Li_xWS₂) was transferred into a centrifuge tube in a nitrogen glovebox. Deionized water (> 18 M Ω cm) that had been degassed for at least 15 min was added into the tube immediately after the tube was transferred out of the glovebox. The tube was sonicated for 1 hr and the temperature was kept below 30 °C. The mixture was centrifuged at 2500 rpm to remove the non-exfoliated TMDCs sheets and 11000 rpm for 15 minutes three times to remove the lithium salt byproducts. The exfoliated MoS₂ and WS₂ suspensions were used immediately after preparation.

Synthesis of metallocene intercalated MoS₂ and WS₂. 15 mL of exfoliated MoS₂/WS₂ suspension was restacked on a nitrocellulose membrane (0.025 μm , MF-Millipore™) by vacuum filtration. After the suspension was filtered, 3 mL of a saturated hexane solution containing the metallocene was added into the filtration funnel while the membrane was still wet. The vacuum filtration proceeded for 1 hour. The material was washed with hexane 4 to 5 times to remove residual metallocene.

Synthesis of n-alkylamine intercalated MoS₂ and WS₂. 15 mL of exfoliated MoS₂/WS₂ suspension was restacked on a nylon membrane (0.2 μm , MF-Millipore™) by vacuum filtration. After the suspension was filtered, 0.2 mmol of n-alkylamine in 6 mL of methanol was added into the filtration funnel while the membrane was still wet. The filtration was carried out under static vacuum. Before the solution in the flask completely dried out, the material was washed with

methanol 4 to 5 times to remove residual alkylamine. The filtration time was not controlled but typically this process takes less than 30 min.

Synthesis of phenazine and *p*-benzoquinone intercalated MoS₂ and WS₂. 15 mL of exfoliated MoS₂/WS₂ suspension was restacked on a nitrocellulose membrane (0.025 μm, MF-Millipore™) by vacuum filtration. After the suspension was filtered, 3 mL of saturated phenazine toluene solution (1.5 mmol of *p*-benzoquinone in 3 mL of toluene) was added into the filtration funnel while the membrane was still wet. The vacuum filtration proceeded for 1 hour. The material was washed with toluene 4 to 5 times to remove residual guest species.

Sample Characterization. X-ray diffraction data were obtained from a Bruker D8 Discover instrument with the I μ S 2-D XRD system. Raman spectra were recorded on a Renishaw Raman Confocal and 514 nm laser was used. Scanning electron microscopy images were obtained from an Apreo variable-pressure SEM. A PerkinElmer Optima 8300 inductively coupled plasma–optical emission spectrophotometer was used for elemental analysis. Solutions of MoS₂ samples were prepared by dissolving the materials in aqua regia whereas WS₂ intercalated samples were digested using a mixture of HF, HNO₃, and H₂O (volume ratio 1:1:1). Microanalysis was conducted by the CENTC Elemental Analysis Facility at the University of Rochester. Microanalysis samples were weighed with a PerkinElmer Model AD6000 Autobalance and their compositions were determined with a PerkinElmer 2400 Series II Analyzer.

Conflicts of interest

There are no conflicts to declare.

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References

- 1 F. R. Gamble, F. J. DiSalvo, R. A. Klemm and T. H. Geballe, *Science*, 1970, **168**, 568–

- 570.
- 2 F. R. Gamble, J. H. Osiecki, M. Cais, R. Plsharody, F. J. DiSalvo and T. H. Geballe, *Science*, 1971, **174**, 493–497.
 - 3 C. Wan, X. Gu, F. Dang, T. Itoh, Y. Wang, H. Sasaki, M. Kondo, K. Koga, K. Yabuki, G. J. Snyder, R. Yang and K. Koumoto, *Nat. Mater.*, 2015, **14**, 622–627.
 - 4 Q. Zhang, L. Mei, X. Cao, Y. Tang and Z. Zeng, *J. Mater. Chem. A*, , DOI:10.1039/D0TA03727C.
 - 5 Y. Jung, Y. Zhou and J. J. Cha, *Inorg. Chem. Front.*, 2016, **3**, 452–463.
 - 6 Qingyong Zhang, Liang Mei, Xiehong Cao, Yuxin Tang and Zhiyuan Zeng, *J. Mater. Chem. A*, 2020, **8**, 15417–15444.
 - 7 N. Feng, R. Meng, L. Zu, Y. Feng, C. Peng, J. Huang, G. Liu, B. Chen and J. Yang, *Nat. Commun.* 2019 101, 2019, **10**, 1–11.
 - 8 M. Mattinen, M. Leskelä and M. Ritala, *Adv. Mater. Interfaces*, 2021, **8**, 2001677.
 - 9 D. Saha and P. Kruse, *J. Electrochem. Soc.*, 2020, **167**, 126517.
 - 10 Y. Liang, H. D. Yoo, Y. Li, J. Shuai, H. A. Calderon, F. C. Robles Hernandez, L. C. Grabow and Y. Yao, *Nano Lett.*, 2015, **15**, 2194–2202.
 - 11 J. T. Ye, Y. J. Zhang, R. Akashi, M. S. Bahramy, R. Arita and Y. Iwasa, *Science*, 2012, **338**, 1193–1196.
 - 12 I. H. Kwak, H. G. Abbas, I. S. Kwon, Y. C. Park, J. Seo, M. K. Cho, J. P. Ahn, H. W. Seo, J. Park and H. S. Kang, *J. Mater. Chem. A*, 2019, **7**, 8101–8106.
 - 13 N. H. Attanayake, A. C. Thenuwara, A. Patra, Y. V Aulin, T. M. Tran, H. Chakraborty, E. Borguet, M. L. Klein, J. P. Perdew and D. R. Strongin, , DOI:10.1021/acsenergylett.7b00865.
 - 14 M. Chhowalla, H. S. Shin, G. Eda, L. J. Li, K. P. Loh and H. Zhang, *Nat. Chem.*, 2013, **5**, 263–275.
 - 15 R. R. Chianelli, J. C. Scanlon, M. S. Whittingham and F. R. Gamble, *Inorg. Chem.*, 1975, **14**, 1691–1696.
 - 16 F. R. Gamble, J. H. Osiecki and F. J. DiSalvo, *J. Chem. Phys.*, 1971, **55**, 3525–3530.
 - 17 G. Zhu, J. Liu, Q. Zheng, R. Zhang, D. Li, D. Banerjee and D. G. Cahill, *Nat. Commun.*, 2016, **7**, 1–9.
 - 18 J. Zheng, H. Zhang, S. Dong, Y. Liu, C. Tai Nai, H. Suk Shin, H. Young Jeong, B. Liu and K. Ping Loh, *Nat. Commun.*, 2014, **5**, 1–7.
 - 19 Z. Zeng, Z. Yin, X. Huang, H. Li, Q. He, G. Lu, F. Boey and H. Zhang, *Angew. Chemie*, 2011, **123**, 11289–11293.
 - 20 chen Wang, Q. He, U. Halim, Y. Liu, E. Zhu, Z. Lin, H. Xiao, X. Duan, Z. Feng, R.

- Cheng, N. O. Weiss, G. Ye, Y. C. Huang, H. Wu, H. C. Cheng, I. Shakir, L. Liao, X. Chen, W. A. Goddard, Y. Huang and X. Duan, *Nature*, 2018, **555**, 231–236.
- 21 Z. Lin, Y. Liu, U. Halim, M. Ding, Y. Liu, Y. Wang, C. Jia, P. Chen, X. Duan, C. Wang, F. Song, M. Li, C. Wan, Y. Huang and X. Duan, *Nature*, 2018, **562**, 254–258.
- 22 M. Laipan, L. Xiang, J. Yu, B. R. Martin, R. Zhu, J. Zhu, H. He, A. Clearfield and L. Sun, *Prog. Mater. Sci.*, 2020, **109**, 100631.
- 23 K. E. Dungey, M. D. Curtis and J. E. Penner-Hahn, *Chem. Mater.*, 1998, **10**, 2152–2161.
- 24 A. A. Jeffery, C. Nethravathi and M. Rajamathi, *J. Phys. Chem. C*, 2014, **118**, 1386–1396.
- 25 J. P. Lemmon and M. M. Lerner, *Chem. Mater.*, 1994, **6**, 207–210.
- 26 I. Saada and R. Bissessur, *J. Mater. Sci.*, 2012, **47**, 5861–5866.
- 27 R. Bissessur, J. Heising, W. Hirpo and M. Kanatzidis, *Chem. Mater.*, 1996, **8**, 318–320.
- 28 W. M. R. Divigalpitiya, R. F. Frindt and S. R. Morrison, *Science*, 1989, **246**, 369–371.
- 29 H. Tagaya, T. Hashimoto, M. Karasu, T. Izumi and K. Chiba, *Chem. Lett.*, 1991, **20**, 2113–2116.
- 30 L. Kosidowski and A. V. Powell, *Chem. Commun.*, 1998, 2201–2202.
- 31 A. A. Jeffery, C. Nethravathi and M. Rajamathi, *RSC Adv.*, 2015, **5**, 51176–51182.
- 32 S. Jeong, D. Yoo, M. Ahn, P. Miro, T. Heine and J. Cheon, *Nat. Commun.*, 2015, **6**, 1–7.
- 33 A. Klechikov, J. Yu, D. Thomas, T. Sharifi and A. V. Talyzin, *Nanoscale*, 2015, **7**, 15374–15384.
- 34 L. Ries, E. Petit, T. Michel, C. C. Diogo, C. Gervais, C. Salameh, M. Bechelany, S. Balme, P. Miele, N. Onofrio and D. Voiry, *Nat. Mater.*, 2019, **18**, 1112–1117.
- 35 M. Acerce, D. Voiry and M. Chhowalla, *Nat. Nanotechnol.*, 2015, **10**, 313–318.
- 36 I. Janica, D. Iglesias, S. Ippolito, A. Ciesielski and P. Samori, *Chem. Commun.*, 2020, **56**, 15573–15576.
- 37 N. Wakabayashi, H. G. Smith and R. M. Nicklow, *Phys. Rev. B*, 1975, **12**, 659–663.
- 38 W. J. Schutte, J. L. De Boer and F. Jellinek, *J. Solid State Chem.*, 1987, **70**, 207–209.
- 39 M. B. Dines, *Science*, 1975, **188**, 1210–1211.
- 40 C. Morrison, H. Sun, Y. Yao, R. A. Loomis and W. E. Buhro, *Chem. Mater.*, 2020, **32**, 1760–1768.
- 41 M. S. Whittingham and A. J. Jacobson, *Intercalation chemistry*, Academic Press, 1982.
- 42 A. Paul, R. Borrelli, H. Bouyanfif, S. Gottis and F. Sauvage, *ACS Omega*, 2019, **4**, 14780–14789.
- 43 P. Gonzalez Rodriguez, H. Yuan, K. J. H. Van Den Nieuwenhuizen, W. Lette, D. J.

- Schipper and J. E. Ten Elshof, *ACS Appl. Mater. Interfaces*, 2016, **8**, 28926–28934.
- 44 N. Chen, L. Ni, J. Zhou, G. Zhu, Y. Zhang, S. Chen, F. Gao, C. Lu, H. Ji, J. Chen, X. Wang, X. Guo, L. Peng, W. Ding and W. Hou, *Sustain. Energy Fuels*, 2018, **2**, 2788–2798.
- 45 A. Espina, C. Trobajo, S. A. Khainakov, J. R. Garcia and A. I. Bortun, *J. Chem. Soc. Dalton Trans.*, 2001, 499–501.
- 46 R. Schöllhorn and A. Weiss, *J. Less-Common Met.*, 1974, **36**, 229–236.
- 47 R. Schöllhorn, E. Sick and A. Weiss, *Zeitschrift für Naturforsch. B*, 1973, **28**, 168–171.
- 48 F. Hof, R. A. Schäfer, C. Weiss, F. Hauke and A. Hirsch, *Chem. – A Eur. J.*, 2014, **20**, 16644–16651.
- 49 X. S. Chu, A. Yousaf, D. O. Li, A. A. Tang, A. Debnath, D. Ma, A. A. Green, E. J. G. Santos and Q. H. Wang, *Chem. Mater.*, 2018, **30**, 2112–2128.

Footnote

† Electronic supplementary information (ESI) available: Raman and UV-Vis spectra, additional XRD data, tabulated lattice constants, and tabulated compositional data. See DOI: